

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: BING-CHANG WU et al. )  
Filed: Herewith )  
For: METHOD FOR FABRICATING A THIN )  
FILM RESIST )

#2  
Prejudgments  
U.S. 1116a  
6-2002

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents  
Washington, D.C. 20231

Dear Sir:

Prior to the examination on merits, please amend the above-identified application as follows:

**IN THE SPECIFICATION:**

Please replace the paragraph beginning on page 1, line 5, with the following rewritten paragraph:

--This application is a divisional application of, and claims the priority benefit of, U.S. application serial No. 09/653,108 filed on August 31, 2000.--

**IN THE CLAIMS:**

Please cancel claims 1-7 without prejudice and disclaimer.

Respectfully submitted,

Dated: 2/7/2002

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